



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Gary W. Ferrell et al

U.S. Serial No: 09/ 034,369

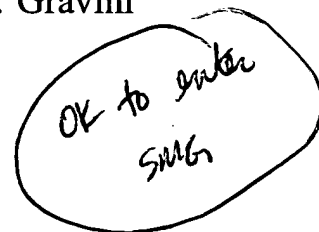
Group Art Unit: 3744

Date Filed: 3 March 1998

Examiner: S. Gravini

Title: "CHEMICAL DRYING AND CLEANING SYSTEM"

Assistant Commissioner for Patents
Washington, D.C. 20231



AMENDMENT AFTER ALLOWANCE

Dear Sir:

In response to the Notice Of Allowance, mailed 15 March 1999, on the above-identified patent application, please enter the following amendments to the application to put the application in better form for publication.

In the specification:

Page 3, line 11, delete "minutes.." and insert - - minutes. - - .

Page 5, line 2, delete "either" and insert - - primarily - - .

Page 5, line 21, after "with" insert - - a weight ratio of - - .

Page 5, line 27, after "mix" insert - - located - - .

Page 7, line 16, after "water" insert - - , - - .

Page 9, line 27, before "workpiece" insert - - portion of a - - ..

Page 16, line 8, delete "apertures" and insert - - aperture - - .

Page 17, line 1, after "horizontally" insert - - or vertically - - .

Date: 15 June 1999

Respectfully Submitted,

John Schipper
John Schipper

Patent Attorney for Applicants